

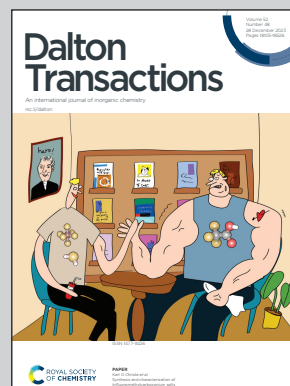
**Showcasing research from Professor Shimojima's laboratory, Waseda University, Japan and Professor Yamazoe's laboratory, Tokyo Metropolitan University, Japan.**

Immobilization of isolated dimethyltin species on crystalline silicates through surface modification of layered octosilicate

Precise control of the local environment and distribution of isolated metal species on silica surfaces is crucial, especially for catalytic applications. In this study, controlled grafting of Sn species was achieved through the reaction of dimethyltin dichloride with the SiOH/SiO<sup>-</sup> groups of crystalline layered octosilicate. Solid-state NMR and X-ray absorption fine structure (XAFS) analyses revealed the bidentate immobilization of the four-coordinated dimethyltin species via the Si-O-Sn bonds. The potential of layered silicates for developing single metal catalysts with a high density of isolated and well-defined active sites is demonstrated.

Artwork by Masashi Yatomi.

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## Immobilization of isolated dimethyltin species on crystalline silicates through surface modification of layered octosilicate†

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Single metal atoms supported on silica are attractive catalysts, and precise control of the local environment around the metal species is essential. Crystalline silica is useful as an efficient support for the incorporation of well-defined metal sites. Dimethyltin species were regularly grafted onto the layer surfaces of layered octosilicate, a type of two-dimensional (2D) crystalline silica. Dimethyltin dichlorides react with the surface silanol (SiOH) groups of the silicate layers. The formation of Si–O–Sn bonds was confirmed by <sup>29</sup>Si magic-angle spinning (MAS) NMR. X-ray absorption fine structure (XAFS) analysis showed the four-coordinated Sn species. These results suggested the presence of well-defined dipodal dimethyltin species on the layer surfaces. The degree of modification of the silanol groups with the dimethyltin groups increased with increasing amounts of dimethyltin dichloride; however, the maximum degree of modification was approximately 50%. This value was interpreted as an alternate modification of the octosilicate reaction sites with dimethyltin groups. These results demonstrate the potential for developing highly active single metal catalysts with a high density of regularly arranged active sites on high surface area supports.

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## Introduction

Single metal atoms immobilized on silica surfaces are used as highly active heterogeneous catalysts for various reactions.<sup>1–5</sup> Precise control of the loading amount, coordination environment, and location of metal species is crucial for improving catalytic activity and understanding the catalytic mechanisms.<sup>4,5</sup> To efficiently utilize isolated metal sites, metal species are generally immobilized on the surface silanols of amorphous silica with a high surface area (e.g., silica gel, fumed silica, and mesoporous silica) or silanol nests in zeolites.<sup>6,7</sup> However, there are challenges with these silica-based supports in terms of controlling the local environment and increasing the amount of metal species. The monopodal metal species can be generated using isolated silanol groups

formed by dehydroxylating amorphous silica at high temperatures under vacuum.<sup>3,8,9</sup> The dipodal metal species are prepared by immobilizing a metal complex bearing bidentate disiloxane ligands.<sup>10</sup> However, amorphous silica has no crystallinity, making it difficult to control the local environment and distribution of the metal species. Zeolites have crystalline structures; however, silanol nests are defect sites obtained by acid treatment to remove Al and B atoms, which limits the amount of introduced metal species to a few wt%.<sup>6,7,11,12</sup> In addition, micropores in the rigid framework of zeolites limit the accessibility of substrates.<sup>13</sup>

Layered polysilicates (also called layered silicates) consist of 2D nanosheets with a crystalline silicate framework alternately stacked with interlayer-exchangeable cations. Silanol (Si–OH) and silanolate (Si–O<sup>−</sup>) groups are arranged regularly and densely on the surfaces of the layers. The modification of these groups enables the design of functional 2D spaces with regularly arranged chemical species.<sup>14,15</sup> Surface modification and interlayer pillaring by immobilizing organosilyl groups and metal species were investigated for applications in catalysis<sup>16,17</sup> and adsorption.<sup>18–20</sup> For immobilizing bulky species between the layers, it is effective to expand the interlayer spaces by exchanging the interlayer alkali metal cations with long-chain alkylammonium cations.<sup>21</sup> Layered polysilicates such as kanemite, layered octosilicate, and RUB-51, which have confronting SiOH/SiO<sup>−</sup> groups on the layer sur-

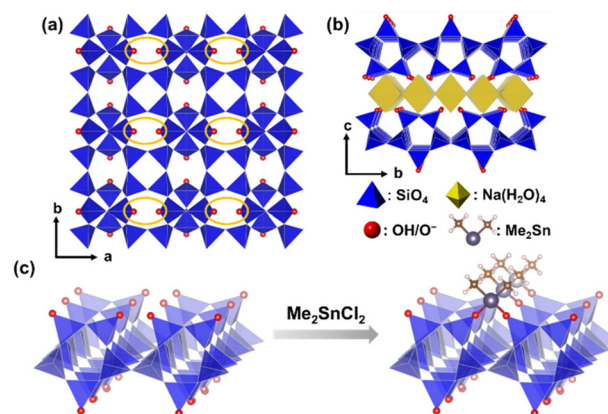
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faces, can be grafted with chlorosilanes ( $R_n\text{SiCl}_{4-n}$ ;  $n = 0-2$ , and  $R'\text{OSiCl}_3$ , where  $R$  and  $R'$  are alkyl groups), producing functional materials with crystalline frameworks with dense and regular arrangements of dipodal silyl groups.<sup>20,22-24</sup> Several reports are available on interlayer swelling<sup>25,26</sup> and exfoliation of the layers,<sup>27,28</sup> enabling the control of substrate accessibility to the interlayer surfaces. Thus, layered polysilicates have the potential to serve as excellent supports for creating well-defined single metal sites, overcoming the aforementioned challenges of amorphous silica and zeolite supports.

The formation of Si–O–M ( $M$  = metal atom) bonds on the surface of layered polysilicates was reported by Tsunoji *et al.* for grafting  $\text{Ti}^{\text{IV}}(\text{acac})_4$  ( $\text{acac}$  = acetylacetonate) onto layered silicates HUS-2<sup>16</sup> and HUS-7.<sup>29,30</sup> These studies showed that the catalytic activity was improved by high loading amounts of Ti and the expansion of interlayer spaces. However, the local environment of  $\text{Ti}(\text{IV})$  was not sufficiently elucidated. Layered zeolites, which are another type of 2D crystalline silicates, were also used as supports for metal species.<sup>31,32</sup> Grosso-Giordano *et al.* immobilized  $\text{Ti}(\text{IV})$  on the surface defect sites of a delaminated MWW-type layered zeolite (UCB-4) and analyzed the local environment of Ti.<sup>32</sup> The precise control of the coordination state of the  $\text{Ti}(\text{IV})$  species and the environment of the surrounding silanol groups resulted in higher catalytic activity compared to metal species supported on amorphous silica. However, the amount of Ti introduced was extremely small because of the limited amount of defect sites, which made it difficult to control the arrangement of metal sites.

To precisely control the immobilization of metal species on layered polysilicates *via* Si–O–M bonds, controlling the number of reaction sites in the metal precursors is essential. When metal alkoxides and chlorides are used as precursors, limiting the number of alkoxy or chloro groups is crucial to prevent the unwanted formation of M–O–M bonds. We have focused on alkyltin chlorides ( $R_n\text{SnCl}_{4-n}$ ) as a metal precursor because the number of highly reactive Sn–Cl bonds can be easily controlled by introducing relatively stable Sn–C bonds.<sup>33-36</sup> This feature of Sn is clearly distinctive from the organometallic compounds of transition metals such as Ti and Zr, where M–C bonds are highly reactive.<sup>37,38</sup> Recently, Sn-modified silica has attracted considerable attention as Lewis acid catalysts. Tetrachlorotin ( $\text{SnCl}_4$ ) reacts with the silanol nest of zeolites to form 4-coordinated isolated  $\text{SnO}_4$ , which acts as a Lewis acid site.<sup>6,11,12,39</sup> Organotin(IV) compounds also exhibit Lewis acidity by controlling the coordination number and introducing electron-withdrawing functional groups.<sup>40-43</sup> Hence, the introduction of alkyltin species into silicate frameworks *via* Si–O–Sn bonds is a promising approach for their use as catalysts. The immobilization of alkyltin species on zeolites and amorphous silica was reported in the literature;<sup>33-35,44</sup> however, these silica supports have the aforementioned limitations that hamper the high density and regular immobilization of Sn species.

In this study, we report the successful immobilization of well-defined, isolated dimethyltin species on the interlayer surfaces of layered octosilicates (Scheme 1). Na-type layered octo-



**Scheme 1** (a) and (b) Structural models of Na-type layered octosilicate and (c) bidentate immobilization of dimethyltin dichloride on the surface of octosilicate.

silicate (RUB-18, Ilerite,  $\text{Na}_8\text{Si}_{32}\text{O}_{64}(\text{OH})_8 \cdot 32\text{H}_2\text{O}$ , named as Na-Oct) has a high density of confronting  $\text{SiOH}/\text{SiO}^-$  groups ( $3.4 \text{ OH per nm}^2$ ) on the layer surface (Scheme 1(a) and (b)). The two Sn–Cl groups of dimethyltin dichloride are expected to react with the confronting  $\text{SiOH}/\text{SiO}^-$  groups, resulting in bidentate immobilization of the dimethyltin groups. Tri- or tetrachlorotin compounds are not suitable because Sn–Cl groups remain on the layers even after bidentate immobilization, which may induce condensation with other Sn species in the presence of water. The degree of dimethyltin modification was tailored by varying the amount of  $\text{Me}_2\text{SnCl}_2$  added to the reaction. Moreover, comparisons were made between these tin-modified samples and those prepared using the silane analogue, dichlorodimethylsilane, to discuss the differences in the interlayer environments. The local environment around the grafted dimethyltin groups was investigated by UV–Vis spectroscopy, X-ray photoelectron spectroscopy (XPS), and X-ray absorption fine structure (XAFS) analysis to identify the state of the immobilized dimethyltin on the layered polysilicates.

## Methods

### Materials

$\text{SiO}_2$  (fumed silica (S5130)) was purchased from Sigma-Aldrich. NaOH (97%), SnO (97%),  $\text{SnO}_2$  (98%), dehydrated pyridine (99.5%), super dehydrated *N,N*-dimethylformamide (DMF, 99.5%), super dehydrated dichloromethane (DCM, 99.5%), dichloromethane (99.5%), and 6 M HCl solution were purchased from FUJIFILM Wako Pure Chemical Corp. Hexadecyltrimethylammonium chloride ( $\text{C}_{16}\text{TMACl}$ , 95% purity), dimethyltin dichloride ( $\text{Me}_2\text{SnCl}_2$ , 99%), dichlorodimethylsilane ( $\text{Me}_2\text{SiCl}_2$ , 98%), and dimethyltin oxide (DMTO, 95%) were purchased from Tokyo Chemical Industry Co., Ltd (TCI). Acetone (99.0%) and hexane (99.0%) were purchased from Kanto Chemical Co., Inc. All the reagents were used without further purification.





### Preparation of layered Na-octosilicate and ion-exchange with C<sub>16</sub>TMACl

Na-Oct and hexadecyltrimethylammonium ion-exchanged octosilicate (C<sub>16</sub>TMA-Oct) were synthesized following the previous reports.<sup>45,46</sup> Fumed silica, NaOH, and deionized water were mixed at a molar ratio of 4:1:25.8 in a Teflon beaker, and the mixture was aged for 1 h. Hydrothermal treatment was conducted in a Teflon-sealed autoclave at 100 °C for 4 weeks. The product was washed with deionized water and air-dried at 45 °C to obtain Na-Oct. The characterization data for Na-Oct are shown in the ESI (Fig. S1–S3 and Tables S1, S2†). Na-Oct (1.5 g) was dispersed in 100 mL of 0.1 M aqueous solution of C<sub>16</sub>TMACl and stirred at room temperature for 24 h. After centrifuging the suspension, the precipitate was washed twice with deionized water. Finally, the product was vacuum-dried at room temperature to obtain C<sub>16</sub>TMA-Oct. The characterization data for C<sub>16</sub>TMA-Oct are shown in the ESI (Fig. S1–S4 and Tables S1, S2†).

### Grafting of dimethyltin dichloride on C<sub>16</sub>TMA-Oct

C<sub>16</sub>TMA-Oct (0.2 g) was dried in a Schlenk flask under vacuum heating at 120 °C for 3 h. After cooling to 100 °C and introducing dried N<sub>2</sub>, DMF (10 mL) and Me<sub>2</sub>SnCl<sub>2</sub> were added, and the mixture was stirred at 100 °C for 2 d. The reaction was performed without adding a base such as pyridine to trap HCl. Me<sub>2</sub>SnCl<sub>2</sub> was added at 0.1, 0.25, 0.5, and 10 equivalents (8, 20, 41, and 811 mg, respectively) against a pair of the reaction sites (SiOH/SiO<sup>−</sup>) on the octosilicate surface. The products were separated by centrifugation (5000 rpm, 5 min), washed three times with acetone, and dried overnight under reduced pressure. The samples were named Me<sub>2</sub>Sn-Oct\_X (X = 0.1, 0.25, 0.5, and 10), where X represents the equivalents of Me<sub>2</sub>SnCl<sub>2</sub>.

### Silylation of C<sub>16</sub>TMA-Oct with Me<sub>2</sub>SiCl<sub>2</sub>

C<sub>16</sub>TMA-Oct (0.2 g) in a Schlenk flask was dried by vacuum heating at 120 °C for 3 h. Dichloromethane (10 mL), pyridine (5 mL), and Me<sub>2</sub>SiCl<sub>2</sub> (0.44 mL) were added under the N<sub>2</sub> atmosphere, and the mixture was stirred at room temperature for 1 d under a nitrogen atmosphere. The silylating agent was 10 equivalents each for the pair of reaction sites (SiOH/SiO<sup>−</sup>) on the octosilicate surface. The product was separated by centrifugation (5000 rpm, 5 min), washed three times with dichloromethane, and dried overnight under reduced pressure. This sample is denoted as Me<sub>2</sub>Si-Oct.

### Synthesis of proton exchanged octosilicate and heat treatment in DMF

The following reference samples were prepared for the detailed characterization of the products using solid-state <sup>29</sup>Si NMR. According to previous reports,<sup>47,48</sup> protonated octosilicates (H-Oct) can be synthesized by treating Na-Oct with aqueous HCl. Na-Oct (2.5 g) was dispersed in 0.1 M HCl aq. (250 mL) in a beaker and stirred at room temperature for 2 d. The resulting suspension was centrifuged, and the supernatant was removed. The resulting solid was washed twice with deionized

water and dried to obtain H-Oct as a white powder. The characterization data for H-Oct are shown in the ESI (Fig. S1–S3 and Tables S1, S2†).

For comparison with dimethyltin-modified samples, H-Oct was treated under the same conditions: 0.1 g H-Oct and 10 mL DMF were stirred at 100 °C for 2 d. The samples were washed three times with acetone and dried under reduced pressure. This sample was named H-Oct heat.

### Characterization

The X-ray diffraction (XRD) patterns were obtained by a parallel method using a Rigaku RINT-Ultima III powder diffractometer (Cu Kα, λ = 0.15418 nm, 40 kV, 40 mA). Solid-state NMR spectra were recorded on a JEOL JNM-ECX400 spectrometer. Samples were packed in 4 mm zirconia sample tubes and spun at 6 kHz. <sup>13</sup>C cross-polarization (CP)/magic-angle spinning (MAS) NMR was measured at a resonance frequency of 99.6 MHz with a recycle delay of 10 s and contact time of 5 ms. <sup>29</sup>Si MAS NMR was measured at a resonance frequency of 78.6 MHz, with a 90° pulse and a recycle delay of 500 s. Chemical shifts for <sup>13</sup>C and <sup>29</sup>Si nuclei were referenced to hexamethylbenzene (CH<sub>3</sub>) at 17.4 ppm and polydimethylsilane at −33.8 ppm, respectively, as external standards. Fourier transform infrared (FT-IR) spectra were obtained using the KBr method on an FT/IR-6100 spectrometer (JASCO). Carbon, hydrogen, and nitrogen contents were measured using a CHN corder-type MT-5 (Yanaco). The heating and oxidation temperatures (conc. 15% O<sub>2</sub>) and temperature at the reduction furnaces were 950, 850, and 550 °C, respectively. The analysis was conducted by A-Rabbit-Science Japan Co., Ltd. The amounts of Si, Na, and Sn were determined using inductively coupled plasma optical emission spectrometry (ICP-OES) (Agilent Technologies, Agilent 5100). Samples were prepared using a melting method with Li<sub>2</sub>B<sub>4</sub>O<sub>7</sub> as the flux. High-resolution scanning electron microscopy (HR-SEM) images were obtained using an S-5500 microscope (Hitachi High Technologies Co.) at an accelerating voltage of 1 kV. Transmission electron microscopy (TEM), high-angle annular dark-field scanning transmission electron microscopy (HAADF-STEM), and STEM-energy dispersive X-ray spectroscopy (EDS) were performed using a JEM-1400Flash microscope (JEOL) at an accelerating voltage of 120 kV. STEM-EDS mapping was performed using a JEOL JED-2300 T detector. XPS spectra were measured using a JPS-9010MX (JEOL) spectrometer using Mg Kα excitation. The C 1p peak at the binding energy of 284.7 eV was used as a reference. Diffuse reflectance (DR) UV-Vis spectra were recorded on a V-660 spectrometer (JASCO) using a BaSO<sub>4</sub> plate as the reference. Sn K-edge XAFS analyses were conducted at the public beamline BL01B1 of SPring-8 at the Japan Synchrotron Radiation Research Institute.<sup>49</sup> The incident X-rays were monochromatized using a Si(311) double-crystal monochromator. The photon energy was calibrated at the inflection point of the Sn K-edge X-ray absorption near-edge structure (XANES) spectrum of the Sn metal foil to 29 194.99 eV. The powdered samples were diluted with an appropriate amount of boron nitride (BN), pressed into pellets, and used



for XAFS measurement. Sn K-edge XAFS spectra were analyzed using xTunes software.<sup>50</sup> After normalization, Fourier-transformation (FT) of  $k^3$ -weighted  $\chi$  spectra in the  $k$  range of 3.0–14.0 Å<sup>−1</sup> was performed to obtain the FT-EXAFS spectra. The curve fitting analysis for samples was conducted in the range of 1.2–1.9 Å using a FEFF8 program.<sup>51</sup> Density functional theory (DFT) calculations for the structural refinement of Me<sub>2</sub>Sn-Oct and DMTO were performed using the BIOVIA Materials Studio software. The CASTEP module was used with the GGA-PBE functional.<sup>52</sup> The energy tolerance was  $2.0 \times 10^{-5}$  eV per atom, force tolerance was 0.05 eV Å<sup>−1</sup>, maximum stress was 0.1 GPa, and displacement tolerance was 0.002 Å. The partial structural model was displayed using the VESTA software.<sup>53</sup>

## Results & discussion

The powder XRD patterns of C<sub>16</sub>TMA-Oct and Me<sub>2</sub>Sn-Oct\_X ( $X = 0.1, 0.25, 0.5$ , and  $10$ ) samples are shown in Fig. 1. C<sub>16</sub>TMA-Oct (Fig. 1(a)) exhibited a diffraction peak at  $2\theta = 3.18^\circ$  ( $d = 2.79$  nm) corresponding to the basal spacing and the in-plane (400) peak of octosilicate at  $2\theta = 49.4^\circ$  ( $d = 0.184$  nm). The basal spacings of Me<sub>2</sub>Sn-Oct\_0.1, \_0.25, \_0.5, and \_10 (Fig. 1(b)–(e)) were 2.79, 1.23, 1.08, and 1.18 nm, respectively. Although the  $d$  value of Me<sub>2</sub>Sn-Oct\_0.1 was nearly unchanged from that of C<sub>16</sub>TMA-Oct, the  $d$  values of Me<sub>2</sub>Sn-Oct\_0.25, \_0.5, and \_10 became much smaller, indicating the elimination of C<sub>16</sub>TMA<sup>+</sup>, which is consistent with the results of the elemental analysis and solid-state <sup>13</sup>C NMR described below. For Me<sub>2</sub>Sn-Oct\_X, the (400) peak gradually shifts to  $48.5^\circ$  ( $d = 0.187$  nm) with increasing the  $X$  value. These shifts suggest the in-plane lattice expansion of the octosilicate owing to the introduction of dimethyltin groups. This is similar to the shifting of the (302) peak of the dealuminated BEA-type zeolite to a lower angle because of the framework expansion due to the introduction of Sn species into the silanol nest.<sup>54</sup>

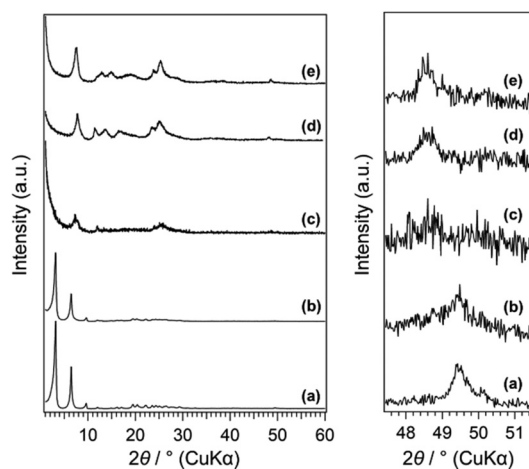


Fig. 1 (A) Powder XRD patterns of (a) C<sub>16</sub>TMA-Oct, (b) Me<sub>2</sub>Sn-Oct\_0.1, (c) Me<sub>2</sub>Sn-Oct\_0.25, (d) Me<sub>2</sub>Sn-Oct\_0.5, and (e) Me<sub>2</sub>Sn-Oct\_10.

The FT-IR spectra of C<sub>16</sub>TMA-Oct and Me<sub>2</sub>Sn-Oct\_X are shown in Fig. 2(A). C<sub>16</sub>TMA-Oct (Fig. 2(A)(a)) showed the bands attributed to CH<sub>2</sub> asymmetric and symmetric stretching vibrations and CH<sub>3</sub> asymmetric and symmetric stretching vibrations of the alkyl groups at 2920, 2850, 2950, and 2870 cm<sup>−1</sup>, respectively.<sup>55</sup> In addition, a band attributed to the Si–OH stretching vibrations on the layer surface was observed at 960 cm<sup>−1</sup>.<sup>56</sup> For Me<sub>2</sub>Sn-Oct\_X (Fig. 2(A)(b)–(e)), the intensities of the C–H stretching vibrations were gradually weakened with increasing  $X$ , suggesting the elimination of the C<sub>16</sub>TMA cations. In the spectra of Me<sub>2</sub>Sn-Oct\_0.5 and Me<sub>2</sub>Sn-Oct\_10 (Fig. 2(A)(d) and (e)), the small bands at 540 and 560 cm<sup>−1</sup> were attributed to Sn–C stretching vibrations.<sup>57–59</sup> For Me<sub>2</sub>Sn-Oct\_X (Fig. 2(A)(b)–(e)), the band of Si–OH groups (960 cm<sup>−1</sup>) decreased from that of C<sub>16</sub>TMA-Oct. A similar decrease was observed upon silylation,<sup>46</sup> suggesting that a condensation reaction occurred between the SnCl and SiOH groups. These results suggest the immobilization of methyltin groups on the layer surfaces.

The FT-IR spectra of Me<sub>2</sub>Sn-Oct\_X ( $X = 0.25, 0.5$ , and  $10$ ; Fig. 2(A)(c)–(e)) showed an absorption band at  $\sim 1700$  cm<sup>−1</sup>, which was attributed to the C=O stretching vibration of acetone. For Me<sub>2</sub>Sn-Oct\_10 (Fig. 2(A)(e)), a sharp absorption band was observed at  $\sim 1650$  cm<sup>−1</sup>, which can be attributed to the C=O stretching vibration of DMF. These results indicated that the solvent used for the reaction and washing remained. Compared with the C=O stretching vibrations of neat acetone and DMF, the C=O bands were observed at lower wavenumbers, suggesting interactions between the carbonyl groups and interlayer silanol groups or immobilized alkyltin groups.<sup>60,61</sup> Although further drying at 120 °C under vacuum was performed for Me<sub>2</sub>Sn-Oct\_10, these solvent molecules could not be removed (Fig. S5†).

The <sup>13</sup>C CP/MAS NMR spectra of C<sub>16</sub>TMA-Oct and Me<sub>2</sub>Sn-Oct\_X ( $X = 0.1, 0.25, 0.5$ , and  $10$ ) are shown in Fig. 2(B). The assignments of the signals of C<sub>16</sub>TMA-Oct are shown in the ESI (Fig. S4†). The spectra of Me<sub>2</sub>Sn-Oct\_X (Fig. 2(B)(b)–(e)) show that the signals derived from the C<sub>16</sub>TMA cations gradually decrease with increasing  $X$ . The C<sub>16</sub>TMA cations were

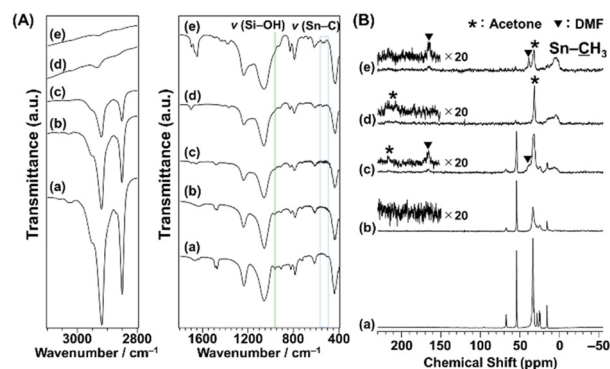


Fig. 2 (A) FT-IR spectra and (B) <sup>13</sup>C CP/MAS NMR spectra of (a) C<sub>16</sub>TMA-Oct, (b) Me<sub>2</sub>Sn-Oct\_0.1, (c) Me<sub>2</sub>Sn-Oct\_0.25, (d) Me<sub>2</sub>Sn-Oct\_0.5, and (e) Me<sub>2</sub>Sn-Oct\_10.



nearly eliminated by adding 0.5 equivalent of  $\text{Me}_2\text{SnCl}_2$ . This result is reasonable because when  $\text{Me}_2\text{SnCl}_2$  reacts with a  $\text{SiOH}/\text{SiO}^-(\text{C}_{16}\text{TMA}^+)$  pair to form two Sn–O–Si bonds,  $\text{C}_{16}\text{TMACl}$  and  $\text{HCl}$  are generated. The generated  $\text{HCl}$  converts the unreacted  $\text{SiO}^-(\text{C}_{16}\text{TMA}^+)$  site to  $\text{SiOH}$  and subsequently generates additional  $\text{C}_{16}\text{TMACl}$  (ESI, Scheme S1†).  $\text{C}_{16}\text{TMACl}$  was finally removed by washing with acetone. In addition, the spectra of  $\text{Me}_2\text{Sn-Oct}_X$  ( $X = 0.25, 0.5$ , and  $10$ ; Fig. 2(B)(c)–(e)) show broad signals at  $\sim 10$  ppm, attributable to the methyl groups attached to Sn ( $\text{CH}_3\text{–Sn}$ ).<sup>62</sup> The signal broadening may have been caused by dipole coupling from the Sn atoms. Furthermore,  $\text{Me}_2\text{Sn-Oct}_X$  exhibited signals attributed to acetone ( $\text{CH}_3$ : 31.7 ppm,  $\text{C=O}$ : 210 ppm) and DMF ( $\text{CH}_3$ : 39 ppm and 33 ppm,  $\text{C=O}$ : 165 ppm), which agreed with the FT-IR results.

The results of the elemental analyses are listed in Table 1. The N/Si ratio of  $\text{C}_{16}\text{TMA-Oct}$  and  $\text{Me}_2\text{Sn-Oct}_X$  ( $X = 0.1, 0.25$ , and  $0.5$ ) gradually decreased with increasing  $X$  ( $0.26 \rightarrow 0.18 \rightarrow 0.07 \rightarrow 0.01$ ), which was owing to the removal of  $\text{C}_{16}\text{TMA}$  cations. The N/Si ratio of  $\text{Me}_2\text{Sn-Oct}_{10}$  (0.08) was higher than that of  $\text{Me}_2\text{Sn-Oct}_{0.5}$  (0.01). This was probably owing to the remaining DMF, as indicated by the FT-IR and solid-state  $^{13}\text{C}$  NMR analyses. The tin content of  $\text{Me}_2\text{Sn-Oct}_X$  gradually increased with increasing  $X$ , indicating a correlation between the elimination of interlayer  $\text{C}_{16}\text{TMA}$  cations and modification with Sn. The Sn/Si ratios of  $\text{Me}_2\text{Sn-Oct}_X$  ( $X = 0.1, 0.25, 0.5$ , and  $10$ ) were 0.03, 0.08, 0.13, and 0.14, respectively (Table 1). Assuming the bidentate immobilization of dimethyltin on all octosilicate reaction sites, the Sn/Si ratio should be 0.25. Therefore, the degrees of modification with Sn of  $\text{Me}_2\text{Sn-Oct}_X$  ( $X = 0.1, 0.25, 0.5$ , and  $10$ ) were 12%, 32%, 52%, and 56%, respectively.

SEM, TEM, and EDS mapping images of  $\text{Me}_2\text{Sn-Oct}_X$  ( $X = 0.1, 0.25, 0.5$ , and  $10$ ) are shown in Fig. 3. All samples exhibited an octosilicate-derived platelet morphology with a uniform distribution of Sn, suggesting the grafting of Sn species on the entire surface of the silicate layers. The EDS mapping image of  $\text{Me}_2\text{Sn-Oct}_{0.1}$  also showed that a larger amount of Sn species was present near the edge region of the plate. EDS quantitative analysis (Fig. 3, right) confirmed that the Sn/Si ratio increased with increasing  $X$  in  $\text{Me}_2\text{Sn-Oct}_X$ . This trend in the local observations is consistent with the overall elemental analysis using ICP-OES and CHN described above.

Fig. 4 shows the solid-state  $^{29}\text{Si}$  MAS NMR spectra of  $\text{C}_{16}\text{TMA-Oct}$  and  $\text{Me}_2\text{Sn-Oct}_X$  ( $X = 0.1, 0.25$ , or  $0.5$ ). For  $\text{C}_{16}\text{TMA-Oct}$  (Fig. 4(a)), signals attributed to  $\text{Q}^3$  ( $\text{Si}(\text{OSi})_3\text{OH}/$

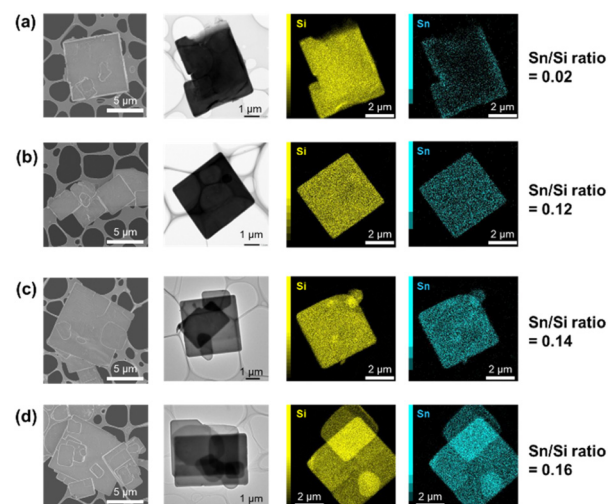


Fig. 3 Electron microscopy images of (a)  $\text{Me}_2\text{Sn-Oct}_{0.1}$ , (b)  $\text{Me}_2\text{Sn-Oct}_{0.25}$ , (c)  $\text{Me}_2\text{Sn-Oct}_{0.5}$ , and (d)  $\text{Me}_2\text{Sn-Oct}_{10}$ . From left to right: SEM images, TEM images, EDS mapping images, and Sn/Si ratios by EDS quantitative analysis.

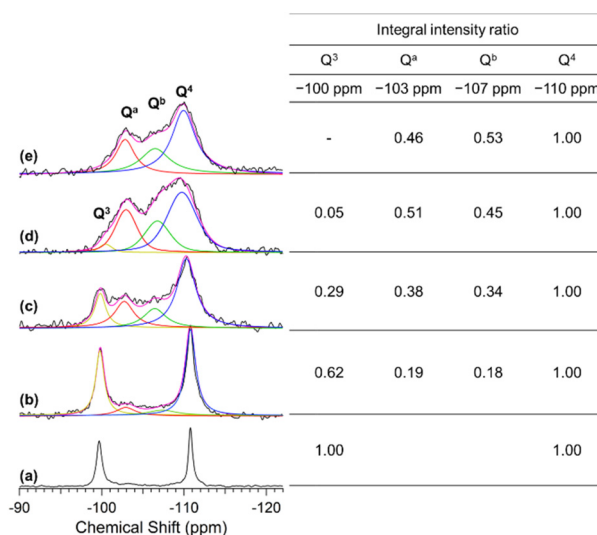


Fig. 4  $^{29}\text{Si}$  MAS NMR spectra of (a)  $\text{C}_{16}\text{TMA-Oct}$ , (b)  $\text{Me}_2\text{Sn-Oct}_{0.1}$ , (c)  $\text{Me}_2\text{Sn-Oct}_{0.25}$ , (d)  $\text{Me}_2\text{Sn-Oct}_{0.5}$ , and (e)  $\text{Me}_2\text{Sn-Oct}_{10}$ . Black lines are the original spectra, pink lines are the fitting spectra, yellow lines indicate the  $\text{Q}^3$  signals at  $-100$  ppm, red lines indicate the  $\text{Q}^a$  signal at  $-103$  ppm, green lines indicate the  $\text{Q}^b$  signal at  $-107$  ppm, and blue lines indicate the  $\text{Q}^4$  signal at  $-110$  ppm. The inserted table shows the relative integral intensity ratio of each signal.

Table 1 Carbon, nitrogen, silicon, and tin contents of the samples

Sample name	C/wt%	N/wt%	Si/wt%	Sn/wt%	N/Si ratio	Sn/Si ratio
$\text{C}_{16}\text{TMA-Oct}$	36.8	2.4	18.7	—	0.26	—
$\text{Me}_2\text{Sn-Oct}_{0.1}$	30.7	2.0	22.1	3.2	0.18	0.03
$\text{Me}_2\text{Sn-Oct}_{0.25}$	13.4	1.0	27.9	9.8	0.07	0.08
$\text{Me}_2\text{Sn-Oct}_{0.5}$	7.1	0.1	30.9	16.6	0.01	0.13
$\text{Me}_2\text{Sn-Oct}_{10}$	7.3	1.1	28.7	17.1	0.08	0.14

$\text{O}^-$ ) and  $\text{Q}^4$  ( $\text{Si}(\text{OSi})_4$ ) sites appeared at  $-100$  and  $-111$  ppm, respectively, with an integral intensity ratio of 1:1.<sup>45</sup> For the spectra of  $\text{Me}_2\text{Sn-Oct}_X$  (Fig. 4(b)–(d)), the integral intensity ratio of the  $\text{Q}^3$  signal to the  $\text{Q}^4$  signal decreased, and new signals appeared at  $-103$  and  $-107$  ppm. For  $\text{Me}_2\text{Sn-Oct}_{10}$ , the original  $\text{Q}^3$  signal disappeared, and signals were observed at  $-103$ ,  $-107$ , and  $-110$  ppm.





Herein, the signals at  $-103$  and  $-107$  ppm were named  $Q^a$  and  $Q^b$ , respectively. The relative integral intensity ratios of the  $Q^3$ ,  $Q^a$ , and  $Q^b$  signals to those of the  $Q^4$  signal are listed in the inset table of Fig. 4. For  $Me_2Sn-Oct\_X$  ( $X = 0.1, 0.25$ , and  $0.5$ ), the sum of  $Q^3$ ,  $Q^a$ , and  $Q^b$  was approximately equal to  $Q^4$ , indicating that the ratio of ( $Q^a + Q^b$ ) coincided with the decrease in the ratio of the  $Q^3$  signal to that of  $C_{16}TMA-Oct$ . Therefore,  $Q^a$  and  $Q^b$  are related to silicon environments that emerge from the reactions of the original  $Q^3$  environments. As described earlier, the introduction of methyltin groups and the elimination of  $C_{16}TMA^+$  were confirmed. Accordingly, these two new environments were assumed to be dimethyltin-modified sites ( $Si(OSi)_3O-Sn$ ) and the confronting disilanol sites ( $Si(OSi)_3OH/Si(OSi)_3OH$ ).

$^{29}Si$  MAS NMR analysis of the proton-exchanged octosilicate (H-Oct) was performed to obtain information on the chemical shifts of the silanol sites. A  $Q^3$  signal was observed at  $-98$  ppm for H-Oct (ESI, Fig. S6(a)†). H-Oct\_heat, obtained by stirring H-Oct in DMF at  $100^\circ C$  for 2 d followed by washing with acetone (see Experimental section), showed that the  $Q^3$  signal shifted to  $-103$  ppm (ESI, Fig. S6(b)†). The retention of acetone in the interlayer spaces of H-Oct\_heat was confirmed using  $^{13}C$  CP/MAS NMR (ESI, Fig. S7†) and XRD (ESI, Fig. S8†), which was consistent with the literature.<sup>47</sup> The  $Q^3$  signal of H-Oct partially shifts to higher fields by heating.<sup>63</sup> Based on these facts, the  $Q^a$  signal observed at  $-103$  ppm for  $Me_2Sn-Oct\_X$  is attributed to the confronting silanol sites ( $Si(OSi)_3OH/Si(OSi)_3OH$ ). The other signal at  $-107$  ppm ( $Q^b$ ) is attributed to dimethyltin-modified sites ( $Si(OSi)_3O-Sn$ ). Such a high-field shift of the  $^{29}Si$  NMR signal owing to bonding with organotin is consistent with a previous report.<sup>64</sup> Furthermore, because the integral intensity ratio of  $Q^b$  corresponds to the amount of Sn-modified Si, the degree of modification with Sn ( $Q^b \times 100$ ) can be estimated. The degrees of Sn modification for  $Me_2Sn-Oct\_X$  ( $X = 0.1, 0.25, 0.5$ , and  $10$ ) were 18%, 34%, 45%, and 53%, respectively, which were in good agreement with those calculated from the Sn/Si ratio by elemental analysis.

With increasing amounts of  $Me_2SnCl_2$ , the elimination of nearly all  $C_{16}TMA$  cations and a decrease in basal spacing were observed (Fig. 1 and 2), indicating that the dimethyltin groups were grafted not only on the outer surface of the layer but also between the layers. In the EDS mapping image of  $Me_2Sn-Oct_{0.1}$  (Fig. 3(a)), the tin species were more clearly visible in the edge region of the octosilicate platelet crystal, suggesting that the dimethyltin immobilization reaction progressed gradually from the edge of the crystal. However, the degree of modification with dimethyltin reached a limit of approximately 50% (Table 1 and Fig. 4), which was lower than the degree of silylation using silane analogues (88% for  $Me_2SiCl_2$ , Fig. S9 and Table S3 in ESI†).

The powder XRD data (Fig. 1) show that the diffraction angles of the 400 planes decreased with increasing amounts of Sn modification, reaching a minimum of  $48.5^\circ$ . The diffraction angle of the 400 planes of  $Me_2Si-Oct$  (ESI, Fig. S10†) was  $48.6^\circ$ , indicating that the lattice expansion was similar to that caused

by a lower degree of modification with the dimethyltin species ( $Me_2Sn-Oct_{10}$ ). It is assumed that the confronting  $SiOH/SiO^-$  groups of octosilicate are distorted by grafting dimethyltin groups because the Sn–O bond is slightly longer than the Si–O bond.<sup>65</sup> The introduction of dimethyltin species into the reaction sites causes in-plane framework expansion, narrowing the distance between the adjacent confronting  $SiOH/SiO^-$  groups. Consequently, the decrease in the reactivity of the narrowed sites prevents the introduction of additional dimethyltin species (ESI, Scheme S2(a)†). Therefore, the silicate layers of  $Me_2Sn-Oct_{10}$  consist of alternate dimethyltin-modified and nonmodified confronting  $SiOH/SiO^-$  sites (ESI, Scheme S2(b)†).

UV-Vis (Fig. 5(A)) measurements were performed to investigate the local environment of Sn in the samples. For the spectra of  $Me_2Sn-Oct\_X$ , a shoulder band was observed at 220 nm. This absorption band was attributed to  $O \rightarrow Sn$  LMCT (ligand to metal charge transfer), generally observed for tin-containing zeolites and mesoporous silica.<sup>66,67</sup> For the UV-Vis spectrum of dimethyltin oxide (DMTO) (Fig. S11†), some broad absorption bands were observed at 200–250 nm, whereas a relatively sharp absorption band was observed for  $Me_2Sn-Oct\_X$ . Thus, the extra-framework DMTO derived from the hydrolytic condensation of  $Me_2SnCl_2$ , an undesired reaction during the synthesis, was negligible.  $Me_2Sn-Oct\_X$  ( $X = 0.25, 0.5$ , and  $10$ ) and H-Oct\_heat exhibited absorption bands at  $\sim 255$  nm. This band was attributed to the  $n \rightarrow \pi^*$  transition of acetone, although it is typically observed at  $\sim 280$  nm.<sup>68</sup> The interaction between the carbonyl groups of acetones and surface silanol groups might cause this shift towards a lower wavelength.

XPS analysis of  $Me_2Sn-Oct\_X$  was also performed (Fig. 5(B)). In the spectrum of  $Me_2Sn-Oct_{0.1}$  (Fig. 5(B)(a)), Sn-derived peaks were observed at 486.2 eV (Sn 3d<sub>5/2</sub>) and 494.7 eV (Sn 3d<sub>3/2</sub>), which gradually shifted towards higher energies up to 487.4 and 495.8 eV with increasing  $X$  (Fig. 5(B)(a)–(d)). The binding energy regions of these peaks correspond to tetravalent Sn. The Sn 3d<sub>5/2</sub> peak of the  $Sn(OSi)_4$  species in tin-containing zeolites appears at  $\sim 487.5$  eV.<sup>69</sup> The Sn 3d<sub>5/2</sub> peak for

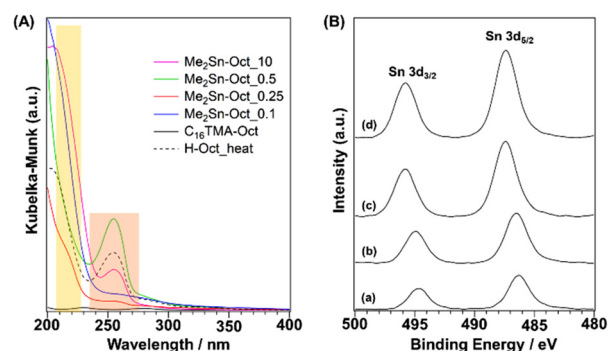


Fig. 5 (A) UV-Vis spectra of  $C_{16}TMA-Oct$ ,  $Me_2Sn-Oct_{0.1}$ ,  $Me_2Sn-Oct_{0.25}$ ,  $Me_2Sn-Oct_{0.5}$ ,  $Me_2Sn-Oct_{10}$ , and H-Oct\_heat. (B) XPS profiles of (a)  $Me_2Sn-Oct_{0.1}$ , (b)  $Me_2Sn-Oct_{0.25}$ , (c)  $Me_2Sn-Oct_{0.5}$ , and (d)  $Me_2Sn-Oct_{10}$ .



Me<sub>2</sub>Sn-Oct\_0.1 appears on the low binding energy side because the central Sn is electron-rich owing to the replacement of two of the four coordinating oxygen atoms with more electron-donating carbon atoms. Shifts in the binding energy towards higher energies for Me<sub>2</sub>Sn-Oct\_X were observed with increasing amounts of tin. This may be associated with the in-plane lattice expansion of the silicate layers, as confirmed by powder XRD. The distortion around Sn became more prominent as grafting was progressed. This distortion may increase the binding energy.<sup>70</sup>

Further detailed information on the local structure of Sn in the samples was obtained using Sn K-edge XAFS analysis. The XANES spectra are shown in Fig. 6(A). The values of absorption edge in each spectrum are listed in Table S4 in ESI.† Sn foil, SnO, SnO<sub>2</sub>, and DMTO were used as the reference samples. DMTO is a five-coordinate organotin compound consisting of Sn bonded to two methyl groups and three oxygen atoms. The two Sn–O–Sn chains interact with each other. Thus, DMTO has a ladder-like structure.<sup>71,72</sup> DMTO was used as a reference sample for dimethyltin compounds. The absorption edges of SnO and SnO<sub>2</sub> were at 29 196.8 and 29 200.6 eV, respectively.

The absorption edge of DMTO was at 29 198.6 eV, indicating a shift in the absorption edge towards lower energies than that of SnO<sub>2</sub>. This shift was owing to the partial substitution of the Sn<sup>4+</sup> surroundings from oxygen atoms to carbon atoms with lower electronegativity, which was consistent with the XPS results. The absorption edges of Me<sub>2</sub>Sn-Oct\_X were shifted to lower energy compared to those of DMTO, suggesting lower coordination numbers. In addition, the values of the absorption edges remained unchanged regardless of the value of X, that is, the degree of dimethyltin modification. This suggested that the local environments of the dimethyltin species were similar.

The *k*<sup>3</sup>-weighted Sn K-edge EXAFS spectra and FT-EXAFS spectra obtained in the range *k* = 3–14 Å<sup>−1</sup> are shown in Fig. 6 (B) and (C). The coordination atoms, coordination numbers, and bond distances around Sn were estimated by curve-fitting the FT-EXAFS spectra. For the reference samples (Sn foil, SnO, SnO<sub>2</sub>, and DMTO; Fig. 6(C)(a)–(d)), the second coordination sphere peaks attributed to Sn–Sn scattering were observed between 2.2 and 3.9 Å. By contrast, no peaks are observed for Me<sub>2</sub>Sn-Oct\_X (Fig. 6(C)(e)–(h)). Elements with different backscattering factors in EXAFS vibrations are less likely to scatter at longer distances. Therefore, the Sn–Si scattering of Sn-containing zeolites with isolated Sn(IV) in the silica framework is very small.<sup>73,74</sup> In the current system, Sn–Si scattering was reasonably absent. In addition, the absence of peaks in this region indicates that only a few Sn–O–Sn bonds were present, indicating that condensation of dimethyltin dichloride did not occur.

The data calculated by curve fitting the FT-EXAFS data are provided in Table 2. The parameters for Sn foil, SnO, and SnO<sub>2</sub> were in good agreement with the previous report.<sup>75</sup> The model of DMTO (ESI, Fig. S12†) was prepared following the previously proposed double-stranded ladder-like structures.<sup>71,72</sup> Although the first coordination sphere consists of oxygen and carbon bonded to Sn, each peak was curve-fitted as Sn–O bonds because these elements have indistinguishable backscattering factors. Therefore, the scattering path is described as Sn–O (C). The first coordination sphere for DMTO had 4.7 coordinating atoms (oxygen or carbon) with distances of 2.08 Å, respectively. Moreover, the peak appearing in the second coordination sphere was the scattering derived from Sn–Sn at a distance of 3.27 Å. Thus, the double-chain ladder structure of dimethyltin oxide proposed in a previous report<sup>71,72</sup> was verified. The Sn–O (C) bond distances for Me<sub>2</sub>Sn-Oct\_X were 2.03 or 2.04 Å, which was shorter than that of DMTO. The Sn–O bond distance in isolated SnO<sub>4</sub> in zeolites is shorter than that in SnO<sub>2</sub> because the coordination number is reduced from 6 to 4.<sup>73</sup> The shorter Sn–O (C) bonds for the dimethyltin-modified octosilicate than that for DMTO with five-coordinated Sn can be explained by the four-coordinated state of the dimethyltin species on the silicate layers. Because the presence of dimethyltin species on the interlayer surfaces has been confirmed by other analyses above, the four-coordinated Sn species suggest the dipodally grafted dimethyltin species. Therefore, the curve fitting results for Me<sub>2</sub>Sn-Oct\_X are consistent with a dimethyltin-grafted

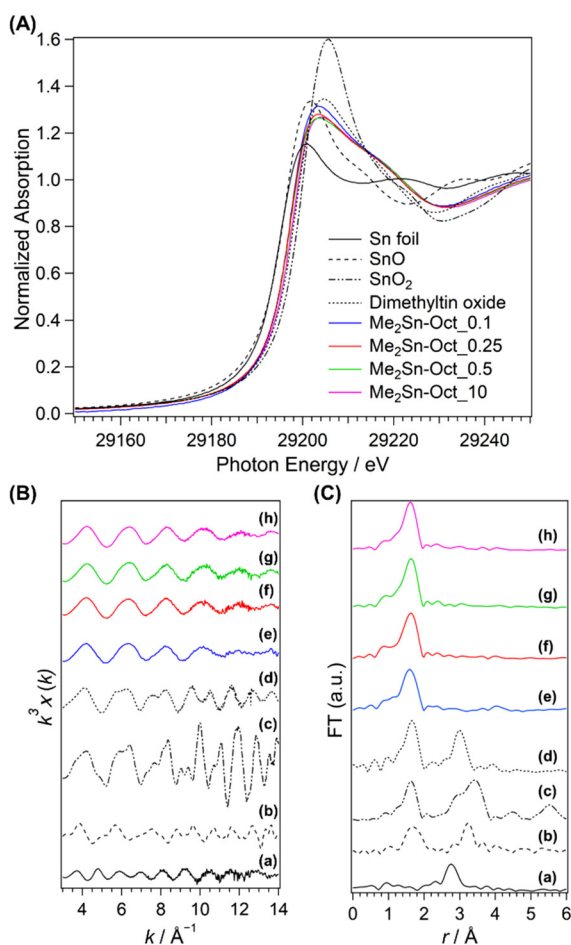


Fig. 6 (A) XANES spectra, (B) EXAFS spectra, and (C) FT-EXAFS spectra of (a) Sn foil, (b) SnO, (c) SnO<sub>2</sub>, (d) dimethyltin oxide (DMTO), (e) Me<sub>2</sub>Sn-Oct\_0.1, (f) Me<sub>2</sub>Sn-Oct\_0.25, (g) Me<sub>2</sub>Sn-Oct\_0.5, and (h) Me<sub>2</sub>Sn-Oct\_10.





**Table 2** Structural parameters of the sample and values from the curve-fitting analysis

Sample name	Path <sup>a</sup>	N <sup>b</sup>	r <sup>c</sup> (Å)	σ <sup>2 d</sup> (Å <sup>2</sup> )	R factor <sup>e</sup>
Sn foil	Sn–Sn	4.0 ± 0.3	3.00 ± 0.04	0.011 ± 0.005	8.0
SnO	Sn–O	4.3 ± 0.4	2.17 ± 0.05	0.009 ± 0.006	10.8
SnO <sub>2</sub>	Sn–Sn	3.0 ± 0.3	3.51 ± 0.04	0.006 ± 0.004	6.4
	Sn–O	5.6 ± 0.2	2.04 ± 0.02	0.003 ± 0.002	8.7
	Sn–Sn	2.3 ± 0.1	3.18 ± 0.02	0.003 ± 0.002	10.5
	Sn–Sn	7.6 ± 0.2	3.74 ± 0.02	0.004 ± 0.002	
DMTO	Sn–O (C)	4.7 ± 0.2	2.08 ± 0.03	0.006 ± 0.003	7.3
	Sn–Sn	2.6 ± 0.2	3.27 ± 0.03	0.005 ± 0.002	8.7
Me <sub>2</sub> Sn-Oct_0.1	Sn–O (C)	4.4 ± 0.3	2.04 ± 0.04	0.006 ± 0.004	9.7
Me <sub>2</sub> Sn-Oct_0.25	Sn–O (C)	4.0 ± 0.2	2.04 ± 0.03	0.005 ± 0.003	10.6
Me <sub>2</sub> Sn-Oct_0.5	Sn–O (C)	4.0 ± 0.2	2.03 ± 0.03	0.005 ± 0.003	10.6
Me <sub>2</sub> Sn-Oct_10	Sn–O (C)	4.0 ± 0.2	2.03 ± 0.03	0.005 ± 0.003	10.4

<sup>a</sup> Path denotes the scattering path of the photoelectrons included in the model. <sup>b</sup> N denotes the coordination number corresponding to the scattering path. <sup>c</sup> r denotes bond length. <sup>d</sup> σ<sup>2</sup> denotes the Debye–Waller factor. <sup>e</sup> R factor =  $(\sum (k^3 \chi^{\text{data}}(k) - k^3 \chi^{\text{fit}}(k))^2)^{1/2} / (\sum (k^3 \chi^{\text{data}}(k))^2)^{1/2}$ .

octosilicate structure model (Fig. S13†). Thus, the Sn K-edge XAFS measurements of Me<sub>2</sub>Sn-Oct\_X revealed the local structure of the dimethyltin groups.

## Conclusions

The interlayer silanol groups of the layered octosilicate were modified with Me<sub>2</sub>SnCl<sub>2</sub>, and the isolated dimethyltin species were grafted onto the surface. The degree of modification increased with increasing amounts of dimethyltin dichloride. When 10 equivalents of Me<sub>2</sub>SnCl<sub>2</sub> were added to the reaction sites, approximately 50% of the total silanol sites of the octosilicate were modified. It was assumed that the larger Sn relative to the confronting silanol site caused the expansion of the framework. Accordingly, a possible structure was proposed in which every other silanol site is modified with dimethyltin groups. This report shows that well-defined metal species can be immobilized on regularly arranged reaction sites on the surfaces of crystalline layered polysilicates. Furthermore, it is notable that the arrangement of the immobilized dimethyltin groups was distinctly different from that of the dimethylsilyl groups when silane analogues were used. The use of layered polysilicates as crystalline silica supports for isolated alkyltin catalysts will become more promising.

## Author contributions

M. Y. designed the study, performed the experiments and material characterization, and wrote the manuscript. T. H. and S. Y. supported the XAFS measurements and analysis. A. S. and K. K. supervised the study. All authors discussed the results, commented on the manuscript, and approved the final version.

## Conflicts of interest

There are no conflicts to declare.

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